

ANALYSIS OF A FILLING COPPER PILLAR BASED ON A THERMAL HOLE GLASS SUBSTRATE FOR A LED CHIP

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ABSTRACT

The glass substrate is drilled thermal holes by UV Laser and then is filled copper pillar on a thermal hole. The taper angles of 5o between top-side via hole and bottom-side via hole are 300 μm in thickness and 1 mm in length for a LED chip. The samples have the diameter/space ratio at 1/2 and 1/4 are fabricated by UV laser and the diameter of 100 ∙ 200 ∙ 300 μm. The made samples filled copper pillar model is used by numerical analysis. The minimum thermal conduction resistance is 3.178 °C/W when a 2x2 array glass copper pillar substrate with 300 μm in diameter and 600 μm in spacing. By finite element method (FEM), the minimum thermal conduction resistance is 3.608 °C/W at the same condition. Thermal conduction resistance of glass substrate is 214.2 9W. The minimum thermal conduction resistance is decreased 98.5 % the thermal conduction resistance based on glass substrate. The numerical analysis results are similar with FEM simulated results. Its tolerance is almost 13.5 %.

KEYWORD: *Laser Drilling, Thermal Hole, Finite Element Method (FEM), Numerical Analysis*

Received: Sep 24, 2015; **Accepted:** Jan 19, 2016; **Published:** Jan 27, 2016; **Paper Id.:** IJEEERFEB201602